Heraeus

# Suprasil® and Infrasil® – Material Grades for the Infrared Spectrum

Operation @946 nm @1064 nm @1319 nm

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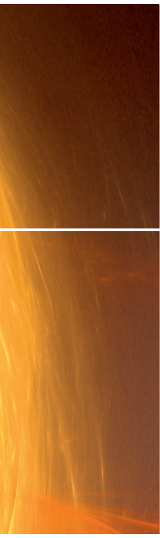
**Operation @946 nm @1064 nm @1319 nm**



The growing need for Infrared Optics especially in high power laser applications, e. g. for material processing, requires special fused silica with the combination of ultra low absorption and optical performance

**Wavelength of Interest**

**946 nm:** Typical Laser Diode wavelength, used for pumping and material processing.
**1040 nm, 1064 nm, 1080 nm:** Nd-doped Lasers, material processing.
**1319 nm:** Nd-doped Lasers, medical applications.

**Suitable Quartz glass**

**Suprasil® 3001, 3002, 300** is the best choice for infrared region.
**Suprasil® 311, 312** very good for 1064 nm.
**Infrasil® 301, 302** is suited for the infrared, especially for longer wavelengths.

| Material | Wavelength | Remark | Application | Performance |
|---|---|---|---|---|
| **Suprasil® 3001** | 200 nm – 3500 nm | Lowest absorption | Highest quality optics | Outstanding |
| **Suprasil® 3002** | 200 nm – 3500 nm | Lowest absorption | Highest quality 2D optics | Outstanding |
| **Suprasil® 300** | 200 nm – 3500 nm | Lowest absorption | Windows, lenses with medium need for homogeneity | Outstanding |
| **Suprasil® 311** | 190 nm – 1100 nm | Very low absorption @ 1064 nm | 3D applications, e. g. high grade prisms | Excellent |
| **Suprasil® 312** | 190 nm – 1100 nm | Very low absorption @ 1064 nm | 2D applications, e. g. lenses, windows | Excellent |
| **Infrasil® 301** | 270 nm – 3500 nm | High cost efficiency | 3D applications, e. g. high grade prisms | Very Good |
| **Infrasil® 302** | 270 nm – 3500 nm | High cost efficiency | 2D applications, e. g. lenses or windows | Very Good |

### Suprasil® 3001, 3002 and 300

Suprasil® 3001, 3002 and 300 are high purity synthetic fused silica materials manufactured by flame hydrolysis. They combine excellent physical properties with outstanding optical characteristics from the UV to the near IR. During the manufacturing process an intermediate drying step reduces the OH content of the Suprasil® 300x to below 1 ppm. A chlorine content of 1000 ppm – 3000 ppm is material inherent and results in a slight shift of the UV-absorption edge to the longer wavelength region.

The Suprasil® 300x family has no absorption bands from the visible to the IR spectral region. This property makes this material family the ideal choice for any low absorption application in the near-IR.

### Infrasil® 301 and 302

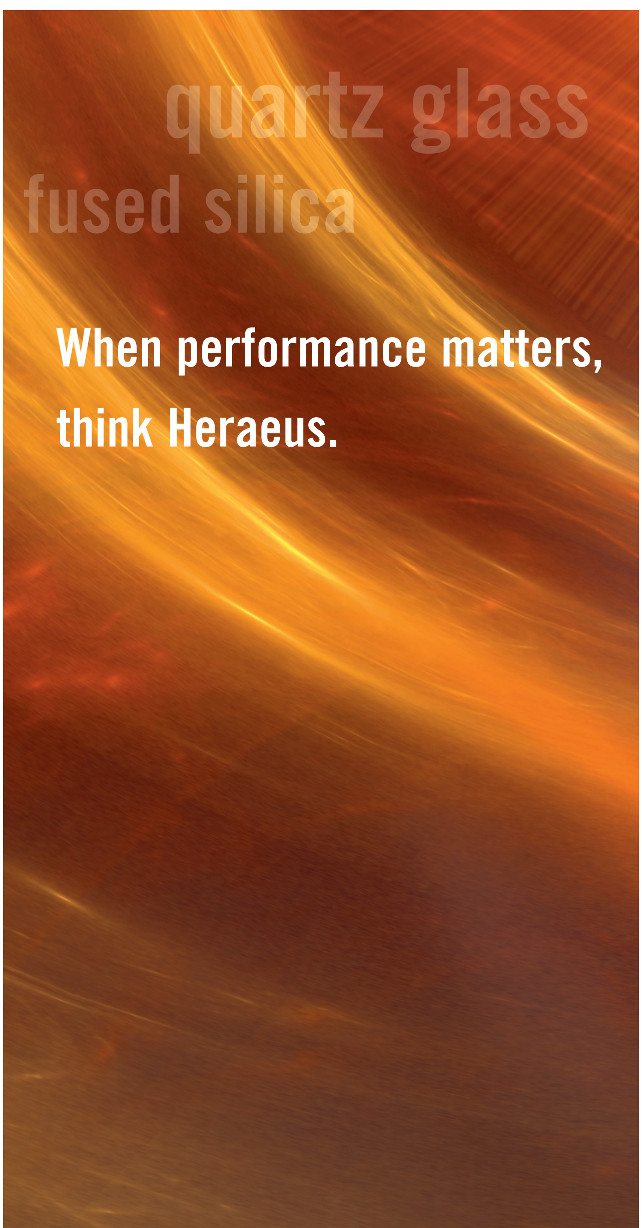
Infrasil® 301 and 302 are optical quartz glass grades manufactured by fusion of natural quartz crystals in an electrically heated furnace. They combine excellent physical properties with outstanding optical characteristics especially in the IR and the visible wavelength range. The index homogeneity is controlled and specified either in one direction (the direction of use or functional direction) or even in all three directions.

## Attenuation

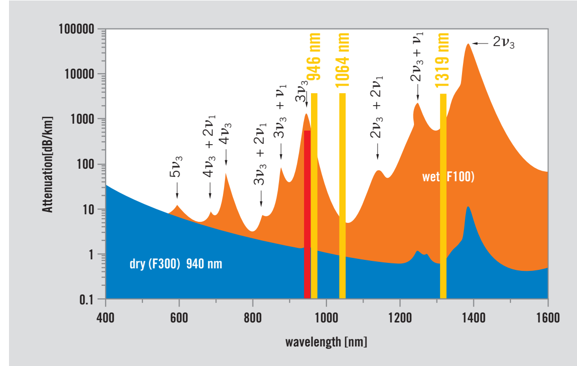
The graphic on the right hand side on top shows the absorption of quartz glass due to OH – molecular vibrational or rotational excitation. In yellow color the relative position of the laser wavelengths with respect to the absorption bands is shown. The red line shows the OH absorption band @ 940 nm.

Synthetic low OH material is the preferred choice for the three laser wavelengths! The bulk absorption can be calculated: x dB/km => x * 2.3 ppm /cm.

This calculated value gives a rough estimate of the order of magnitude of the absorption.
Example: The attenuation @ 940 nm = 2 dB/km
=> Absorption ~ 4.6 ppm/cm

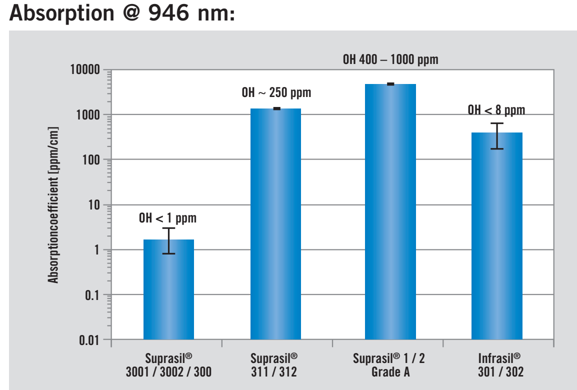



### Attenuation:



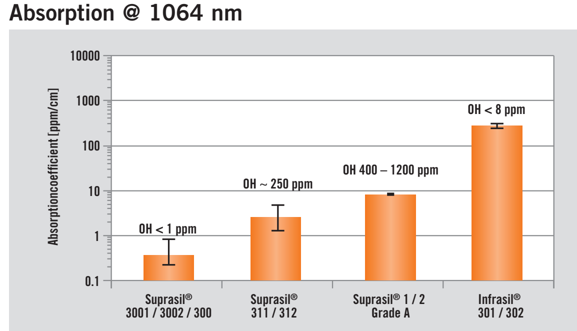

Source: O.Humbach et al., J. Non Crystalline Solids, 203 (1996)

### Absorption @ 946 nm:



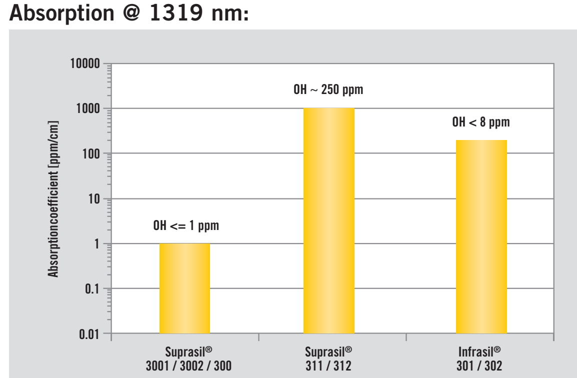

Data by measurements from: Dr. Mühlig, Institut für Photonische Technologien (IPHT) , Jena

### Absorption @ 1064 nm




Data by measurements from:
Dr. Kondilenko, Ginzton Lab, Stanford University, USA, Dr. Pinard, Labo-ratoire des Matériaux Avancés, Lyon, France, Dr. Mühlig, Institut für Photonische Technologien (IPHT), Jena, Priv. Communications

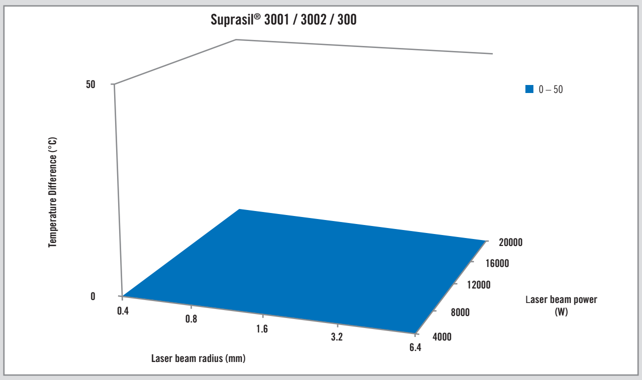
### Absorption @ 1319 nm:




Data by measurements from: Dr. Kondilenko, Ginzton Lab, Stanford University, USA

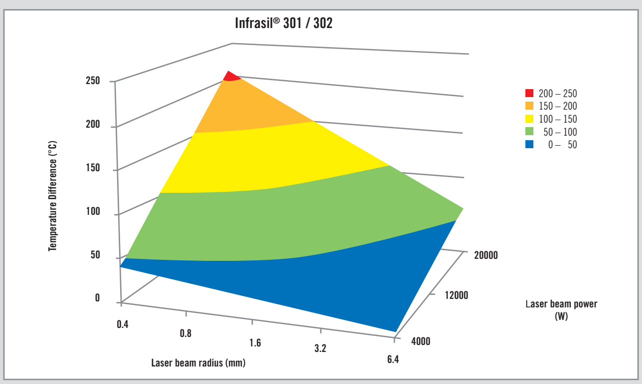
**Absorption @ 946 nm:**

- Absorption can lead to an increase in temperature.
- Absorption also depends on laser beam irradiated area (or beam size).
- The following graphics show a simulation based on
  – Steady-state diffusion equation with bulk and surface heat sources.
  – Convective cooling with a heat transfer coefficient of 10 W/(m²*K) and ambient temperature of 25°C.



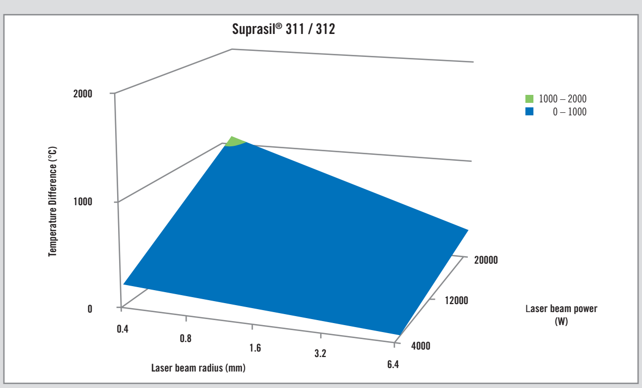

**Suprasil® 3001 / 3002 / 300**

- The simulation shows only a negligible increase in temperature due to bulk absorption.
- Even laser powers up to 20 kW show an extremely low temperature increase due to bulk absorption.



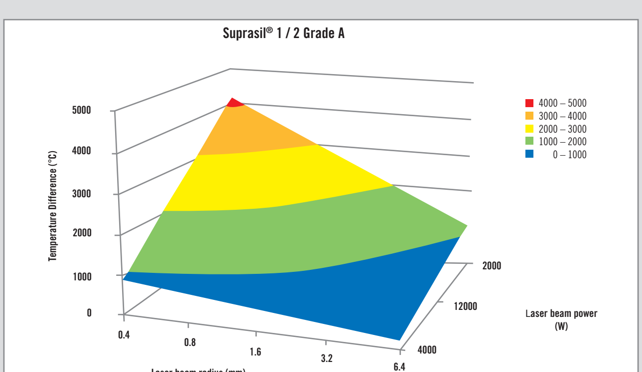

**Infrasil® 301 / 302**

- For a given input power, decreasing the laser beam size, increases the power density (W/sq.cm) resulting in more absorption and a higher temperature rise.
- The temperature rises with a decrease in the laser beam size.
- The temperature rises with an increase in laser power.
- This is due to the bulk absorption of the material Infrasil® 302.
- The maximum temperature is slightly above 200°C for 20 kW and a laser beam radius of 0.4 mm.




**Suprasil® 311 / 312**

- The simulation shows an increase in temperature due to bulk absorption for rising laser powers.
- An increase in temperature can be seen for decreasing laser beam sizes.
- For laser powers up to 20 kW and a laser beam size radius of 0.4 mm the simulation shows a temperature increase to over 1000°C due to bulk absorption.

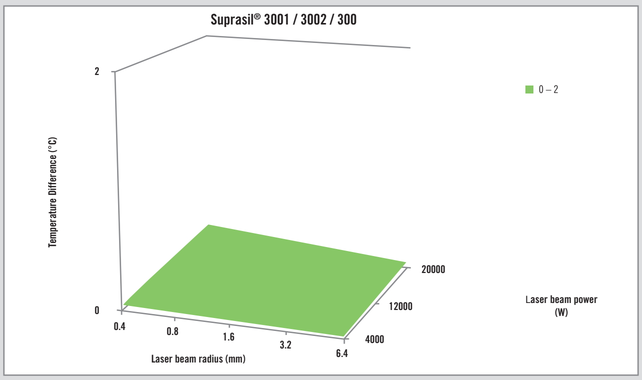



**Suprasil® 1 / 2 Grade A**

- The temperature dependence on beam size and laser power is clearly visible and up to ~5x to~20x to higher than Suprasil® 311 / 312 (OH ~250) and Infrasil (OH < 8 ppm) respectively. In this case absorption and temperature rise is dominated by OH content.
- The temperature rises with a decrease in the laser beam size.
- The temperature rises with an increase in laser power.
- The high OH content leads to a huge increase in temperature because of the bulkabsorption of the Suprasil® 1 @ 946 nm.
- Temperatures above 1700°C are not realistic and failure in coating and or the optic substrate would occur before this.

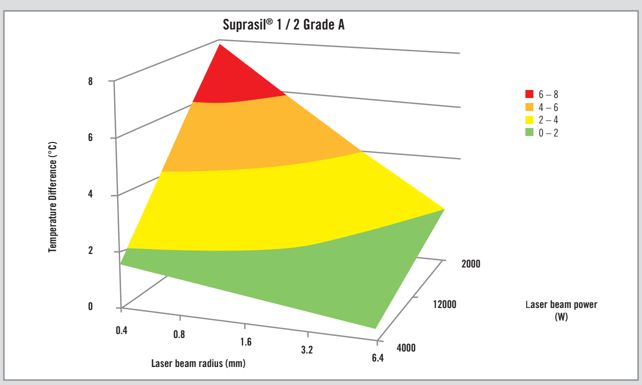
**Absorption @ 1064 nm:**

- Absorption @ 1064 nm is dependent on both impurity level & OH content.
- Absorption also depends on laser beam irradiated area (or beam size).
- Absorption does depend on the laser spot size.
- The following graphics show a simulation based on
  - Steady-state diffusion equation with bulk and surface heat sources.
  - Convective cooling with a heat transfer coefficient of 10 W/(m²*K) and ambient temperature of 25°C.




**Suprasil® 3001 / 3002 / 300**

- The simulation shows a negligible increase in temperature due to bulk absorption.
- Even laser powers up to 20 kW show an extremely low temperature increase due to bulk absorption.

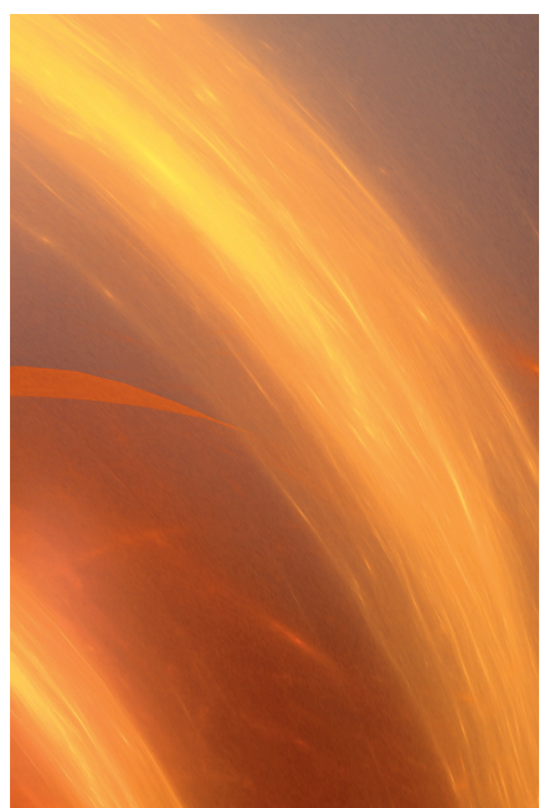



**Suprasil® 1 / 2 Grade A**

- The temperature dependence on beam size and laser power is visible.
- The temperature rises with a decrease in the laser beam size.
- The temperature rises with an increase in laser power.
- The maximum temperature is around 8°C for 20 kW and a laser beam radius beam size 0.4 mm.
- The OH content of Suprasil® 1 has only a very small contribution to the bulk absorption @ 1064 nm.

# Summary

- **OH absorption bands strongly influence performance. Impurity level also plays a role, depending on laser line proximity to key OH absorption lines.**
- **Low OH grades show lower absorption in the IR.**
- **High OH content may lead to lens heating and changes to the index homogeneity and aberrations to the transmitted wave front.**
- **Suprasil® 3001, 3002, 300 is the best choice for infrared applications where performance must be optimized.**
- **Infrasil® 301, 302 is a suitable alternative for applications requiring combined very good NIR performance and economy.**



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HQS Material Grades for the Infrared Spectrum 05.2011/N1.0_E